

L Number	Hits	Search Text	DB	Time stamp
-	5078	(two or dual or auxiliary or second) adj4 (ELECTRON ADJ beam\$1)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/11 15:41
-	223	(two or dual or auxiliary or second) adj4 (ELECTRON ADJ beam\$1) AND SECOND ADJ5 ENERGY	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/22 18:33
-	3750	(electron adj beam) and imag\$3 and (secondary adj electron\$1)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 13:53
2	6038018.pn.		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 08:43
2	6172363.pn.		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 13:41
-	103	electron adj image near3 detector	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 14:00
-	4448	250/310 and excess adj3 charge or charge adj (buildup or accumulation) or charge adj3 neutraliz\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 16:51

	33	electron adj beam and inspect\$3 and charge adj neutraliz\$5	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 13:24
2	6172363.pn.		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 13:24
	1225	(electron adj beam) and imag\$3 and (secondary adj electron\$1) and via	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 13:53
48		(electron adj beam) and imag\$3 and (secondary adj electron\$1) and via and neutralize	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/08 16:55
	14376	(electron adj beam) and energy and via	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 14:17
0		sem and (seccondary adj electron near3 filter)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 14:18
21		sem and (secondary adj electron near3 filter)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 14:26
21		sem and (secondary adj electron near3 filter)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/03 14:33

26	leybourne.xa		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2003/12/03 14:39
401	(semiconductor or wafer) and via near3 inspect\$3			
59	((semiconductor or wafer) and via near3 inspect\$3) and electron adj beam			
0	sem and energy adj filter and band adj -pass			
5	"5097127"		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2003/12/03 14:40
20	"4896036"		2003/12/10 15:25	
0	"4896036" and (excess adj3 charge or charge adj (buildup or accumulation) or charge adj3 neutraliz\$4) and electron adj beam and inspect\$3		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2003/12/08 16:15
5	"5097127"		2003/12/08 16:31	

25	"3896308"	USPAT; US-PPGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PPGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PPGPUB; EPO; JPO; DERWENT;	2003/12/08 16:39
17	"4896045"	USPAT; US-PPGPUB; EPO; JPO; DERWENT;	2003/12/08 16:39
593	250/\$.cccls. and sem and (height or depth)	2003/12/08 16:57	
238	250/\$.cccls. and sem and (height or depth) and charge	2003/12/08 17:39	
18	250/\$.cccls. and sem and (height or depth) and charge adj3 (neutralization control buildup)	2003/12/08 16:59	
51	250/\$.cccls. and sem and (aspect adj ratio) and charge	2003/12/08 17:40	
4	250/\$.cccls. and sem and (aspect adj ratio) and charge adj3 (neutralization control buildup)	2003/12/10 11:34	
9	250/\$.cccls. and sem and (photons or photo adj electrons) and charge adj3 (neutralization control buildup)	2003/12/10 11:56	

1059	(bandpass or band-pass pr band adj pass) near4 energy	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/11 16:12	
33	((bandpass or band-pass pr band adj pass) near4 energy) and secondary adj electron\$1	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/11 16:03	
13	((bandpass or band-pass pr band adj pass) near4 energy) and secondary adj electron\$1 and image	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/11 16:10	
66062	energy near4 (first or second)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/11 16:11	
13276	energy near4 (first or second) and image	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/11 16:11	
104	(bandpass or band-pass pr band adj pass) near4 energy and energy near4 (first or second) and image	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/11 16:12	
2457877	high adj aspect or via or steep adj wall\$1	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/29 13:43	
202	(photon adj beam or laser adj beam) and (photoemission)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/29 13:44	

